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(54) Title: DETACHABLE SUBSTRATE WITH CONTROLLED MECHANICAL HOLD AND METHOD FOR PRODUCTION THEREOF

(54) Titre : SUBSTRAT DEMONTABLE A TENUE MECANIQUE CONTROLEE ET PROCEDE DE REALISATION

(57) Abstract: The invention relates to a method for production of a detachable substrate, comprising a method step for the production of an interface by means of fixing, using molecular adhesion, one face of a layer on one face of a substrate, in which, before fixing, a treatment stage for at least one of said faces is provided, rendering the mechanical hold at the interface at such a controlled level to be compatible with a subsequent detachment.

(57) Abrégé : Procédé de préparation d'un substrat démontable, comportant une étape de réalisation d'une interface par collage par adhésion moléculaire d'une face d'une couche sur une face d'un substrat , dans lequel est prévu, avant collage, une étape de traitement de l'une au moins de ces faces propre à mettre la tenue mécanique de l'interface à un niveau contrôlé compatible avec un démontage ultérieur.

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